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10/07/95



U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
SL	5,454,901	10/3/95	Tsuji			
↑	5,676,760	10/14/97	Aoki, et al.			
	5,762,779	6/9/98	Shiramizu, et al.			
	5,783,790	7/21/98	Mitsumori, et al.			
	5,927,305	7/27/99	Shiba			
	6,082,373	7/4/00	Sakuurai			
	6,115,867	9/12/00	Nakashima, et al.			
↓	6,156,661	12/5/00	Small			
SL	6,199,563	3/13/01	Uehara			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
SL	9-157692	6/17/97	Japan				
	7-263430	10/13/95	Japan				
	9-100494	4/15/97	Japan				
	6-196461	7/15/94	Japan				
SL	6-116770	4/26/94	Japan				

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

SL	"APOST-CMP CLEANING OF W AND SiO ₂ : A MODEL STUDY", by Igor J. Malik, et al., 1995 Materials Research Society, Soc. Symp. Proc. Vol. 386, pages 109-114,
SL	A Electrochemistry Handbook", 4th edition, pages 276-277.

EXAMINER

Sreed Chandrasekhar

DATE CONSIDERED

2/18/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.